

	L #	Hits	Search Text	DBs
1	L1	4474	(black adj (matrix or matrices or mask\$4) or light adj (shield\$6 or shad\$6)).ti,ab.	US-PGPUB; USPAT
2	L2	14730	((particle or particulat\$6 or colloid\$6) near5 (metal\$6 or conduct\$6 or silver or ag)).ti,ab.	US-PGPUB; USPAT
3	L3	27	1 and 2	US-PGPUB; USPAT
4	L4	948	430/7.ccls.	US-PGPUB; USPAT
5	L5	11	2 and 4	US-PGPUB; USPAT
6	L6	6	5 not 3	US-PGPUB; USPAT
7	L7	2019	349/106,110.ccls.	US-PGPUB; USPAT
8	L8	12	2 and 7	US-PGPUB; USPAT
9	L9	4	8 not (3 or 5)	US-PGPUB; USPAT
10	L10	39488	(black adj (matrix or matrices or mask\$4) or light adj (shield\$6 or shad\$6))	US-PGPUB; USPAT
11	L11	141394	((particle or particulat\$6 or colloid\$6) near5 (metal\$6 or conduct\$6 or silver or ag))	US-PGPUB; USPAT
12	L12	201	10 with 11	US-PGPUB; USPAT
13	L15	126	(1 or 4 or 7) and 12	US-PGPUB; USPAT
14	L16	101	15 not (3 or 5 or 8)	US-PGPUB; USPAT
15	L17	50	ito-hideaki.in.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
16	L18	5	1 and 17	US- PGPUB; USPAT
17	L19	38923	(black adj (matrix or matrices or mask\$4) or light adj (shield\$6 or shad\$6))	EPO; JPO; DERWE NT; IBM_TDB
18	L20	71725	((particle or particulat\$6 or colloid\$6) near5 (metal\$6 or silver or ag))	EPO; JPO; DERWE NT; IBM_TDB
19	L21	213	19 and 20	EPO; JPO; DERWE NT; IBM_TDB
20	L22	108	19 with 20	EPO; JPO; DERWE NT; IBM_TDB
21	L26	2120142	photosensitiv\$8 or photopolymer\$8 or resist or photoresist or crosslink\$8 or cross adk link\$8 or photocross\$8 or (light or uv or ultraviolet or irradiat\$8 or radiat\$8) near3 (sensitiv\$8 or polymer or polymeriz\$8 or polymeris\$8)	EPO; JPO; DERWE NT; IBM_TDB
22	L27	77	21 and 26	EPO; JPO; DERWE NT; IBM_TDB
23	L28	45	27 not 22	EPO; JPO; DERWE NT; IBM_TDB

	L #	Hits	Search Text	DBs
24	L29	1487290	transfer\$8 or laminat\$8 or dry adj film	EPO; JPO; DERWE NT; IBM_TDB
25	L30	31	21 and 29	EPO; JPO; DERWE NT; IBM_TDB
26	L31	6	30 not (22 or 27)	EPO; JPO; DERWE NT; IBM_TDB